

(11) **EP 0 878 824 A3** 

(12)

## **EUROPEAN PATENT APPLICATION**

(88) Date of publication A3: 19.01.2000 Bulletin 2000/03

(51) Int Cl.7: H01J 37/32

(43) Date of publication A2: 18.11.1998 Bulletin 1998/47

(21) Application number: 98303196.4

(22) Date of filing: 24.04.1998

(84) Designated Contracting States:

AT BE CH CY DE DK ES FI FR GB GR IE IT LI LU

MC NL PT SE

Designated Extension States:

AL LT LV MK RO SI

(30) Priority: 13.05.1997 GB 9709659

(71) Applicant: Surface Technology Systems Limited Gwent, Wales NP1 9UJ (GB) (72) Inventors:

- McQuarrie, Andrew Duncan
   San Jose, California 95132 (US)
- Boman, Lee Campbell Belmont, California 94002 (US)
- (74) Representative:

   Dunlop, Brian Kenneth Charles et al
   c/o Wynne-Jones, Lainé & James

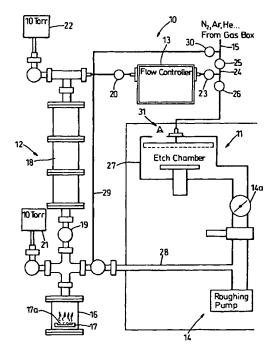
   22 Rodney Road

   Cheltenham Gloucestershire GL50 1JJ (GB)

## (54) Method and apparatus for etching a workpiece

(57) An XeF<sub>2</sub> source 12 comprises a XeF<sub>2</sub> source chamber 16, which includes a tray or ampoule 17 for XeF<sub>2</sub> crystals 17a, a reservoir 18 via valve 19, a flow controller 13 fed by the reservoir 18 and a valve 20 be-

tween the reservoir 18 and the controller 13. Pressure sources 21 and 22 are provided respectively to maintain the reservoir 18 and the source chamber 16 at the sublimination pressure of  $XeF_2$ . The arrangement allows for a steady supply of  $XeF_2$  to an etching chamber.





## **EUROPEAN SEARCH REPORT**

Application Number EP 98 30 3196

Category	Citation of document with ind of relevant passag	ication, where appropriate, jes	Rele to cl	vant aim	CLASSIFICATION APPLICATION	ON OF THE
E	PATENT ABSTRACTS OF vol. 1998, no. 13, 30 November 1998 (19 & JP 10 209088 A (MI CORP), 7 August 1998 * abstract *	98-11-30) TSUBISHI FLECTRIC	1-3,	6,8	H01J37/32	
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					TECHNICAL FI	
					HO1J	(Int.Cl.6)
	The present search report has been drawn up for all claims					
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## ANNEX TO THE EUROPEAN SEARCH REPORT ON EUROPEAN PATENT APPLICATION NO.

EP 98 30 3196

This annex lists the patent family members relating to the patent documents cited in the above-mentioned European search report. The members are as contained in the European Patent Office EDP file on The European Patent Office is in no way liable for these particulars which are merely given for the purpose of information.

25-11-1999

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For more details about this annex : see Official Journal of the European Patent Office, No. 12/82

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